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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: )  
SOBEK, et al. )  
Serial No.: 09/885,426 )  
Filed: June 19, 2001 )  
For: A SILICIDED BURIED )  
BITLINE PROCESS FOR A )  
NON-VOLATILE MEMORY )  
CELL )

Examiner: TRAN, THIEN F.  
Art Unit: 2811

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Assistant Commissioner of Patents  
and Trademarks  
Washington, D.C. 20231

Dear Sir:

RESPONSE TO RESTRICTION REQUIREMENT

In the Office Action mailed June 18, 2002, the Examiner has stated that the present Application contains claims directed to two distinct inventions, Invention I and Invention II. Specifically, the Examiner contends that the first invention, Invention I, is represented by Claims 1-13 and is drawn to a semiconductor device, classified in class 257, subclass 314. The Examiner further contends that the second invention, Invention II, is represented by Claims 14-30 and is drawn to process for making semiconductor devices, classified in class 438, subclass 22+. As such, the Examiner has required Applicants to elect an invention for prosecution on the merits.